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APPLICATION NUMBER	FILING or 371(c) DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	TOT CLAIMS	IND CLAIMS
10/645,822	08/22/2003	1656	920	2750-1571P	17	3

CONFIRMATION NO. 7309

2292
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UPDATED FILING RECEIPT



Date Mailed: 03/13/2009

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. **If an error is noted on this Filing Receipt, please submit a written request for a Filing Receipt Correction. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections**

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Domestic Priority data as claimed by applicant

This application is a CIP of 09/754,184 01/05/2001 ABN
and is a CIP of 10/409,117 04/09/2003 ABN

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and said 10/409,117 04/09/2003
is a CON of 10/084,376 02/28/2002 ABN
which is a CON of 09/924,701 08/09/2001 ABN
which claims benefit of 60/224,391 08/09/2000

Foreign Applications

If Required, Foreign Filing License Granted: 09/15/2004

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US 10/645,822**

Projected Publication Date: 06/18/2009

Non-Publication Request: No

Early Publication Request: No
Title

Sequence-determined DNA fragments and corresponding polypeptides encoded therapy

Preliminary Class

435

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